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Application ID: 10613620 
Title of Invention: Simple Chemical Vapor
Deposition System and Methods
for Depositing Multiple-Metal
Aluminide Coatings
First Named Inventor: David Fairbourn
Domestic/Foreign Application: Domestic Application
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Filing Type:
Confirmation number: 4378
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**TRANSMITTAL**

Electronic Version v1.1

Stylesheet Version v1.1.0

Title of Invention	Simple Chemical Vapor Deposition System and Methods for Depositing Multiple-Metal Aluminide Coatings	
Application Number: 10/613620 		
Date: 2003-11-04		
First Named Applicant: David C Fairbourn		
Confirmation Number: 4378		
Attorney Docket Number: MTCL09		
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Submitted by:	Elec. Sign.	Sign. Capacity
William R Allen Registered Number: 48389	William R. Allen	Attorney
Documents being submitted us-ids		Files MTCL09-usidst.xml us-ids.dtd us-ids.xsl
Comments		



ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18
Stylesheet Version v18.0

Title of Invention

Simple Chemical Vapor Deposition System and Methods for
Depositing Multiple-Metal Aluminide Coatings

Application Number: 10/613620



Confirmation Number: 4378

First Named Applicant: David Fairbourn

Attorney Docket Number: MTCL09

Search string: (2598957 or 2816048 or 3329601 or 3486927
or 3507248 or 3556744 or 3801357 or 3979534
or 4084025 or 4101714 or 4220460 or 4327134
or 4396213 or 4427720 or 4641603 or 4625678
or 4694036 or 4699084 or 4687684 or 4816291
or 4961958 or 4935193 or 4963395 or 5071678
or 5114559 or 5261963 or 5308399 or 5368648
or 5377429 or 5439525 or 5451258 or 5455071
or 5632820 or 5750436 or 5820641 or 5823416
or 5851293 or 5902406 or 6083321 or 6089184
or 6143361 or 6156123 or 6254983 or 6258461
or 6332926 or 6605161).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
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	2	2816048	1957-12-10	Galmiche		117	107
	3	3329601	1967-07-04	Mattox		204	298
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	5	3507248	1970-04-21	Seeley et al.		118	48
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	43	6254983	2001-07-03	Namiki	B1	428	336
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	46	6605161	2003-08-12	Fairbourn	B2	148	243

Signature

Examiner Name	Date